Author's Accepted Manuscript

Surface nanocrystallization of Cu and Ta by sliding friction

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www.elsevier.com/locate/msea

PII: S0921-5093(14)00380-3 DOI:<http://dx.doi.org/10.1016/j.msea.2014.03.089> Reference: MSA30938

To appear in: Materials Science & Engineering A

Received date: 24 January 2014 Revised date: 24 March 2014 Accepted date: 25 March 2014

Cite this article as: Y.S. Zhang, P.X. Zhang, H.Z. Niu, C. Chen, G. Wang, D.H. Xiao, X.H. Chen, Z.T. Yu, S.B. Yuan, X.F. Bai, Surface nanocrystallization of Cu and Ta by sliding friction, Materials Science & Engineering A, [http://dx.doi.org/10.1016/j.](http://dx.doi.org/10.1016/j.msea.2014.03.089) [msea.2014.03.089](http://dx.doi.org/10.1016/j.msea.2014.03.089)

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25 **1. Introduction**

26 A new family of severe plastic deformation processes have attracted considerable 27 scientific interests in order to generate nanocrystalline surface layer for bulk materials 28 [1]. Various surface deformation techniques have been developed by transforming the 29 initial coarse-grained (CG) structure of a bulk material into refined-grain structure, 30 such as surface mechanical attrition treatment (SMAT) [1], air blast shot peening [2], 31 wire-brushing [3], and surface mechanical grinding treatment (SMGT) [4]. These 32 advances enhance several types of mechanical properties while keeping the overall 33 chemical composition of the target material unchanged.

34 Friction is a dissipative process encountered in daily life and industry 35 manufacture. Many experimental results have illustrated that microstructure in the 36 near-surface layer might be changed accordingly during friction and wear process 37 under different contact conditions. Surface microstructure observations showed that 38 plastic deformation could result in the formation of grains with a size falling into 39 nanometer regime. Grains in the surface layer of pure copper with a size less than 60 40 nm have been found in an early study on subsurface structure of pure copper abrased 41 against SiC paper [5]. After sliding against the zirconia disc, the grain size in the 42 surface of the 316 stainless steel could be refined to 8-23 nm [6]. According to 43 Hughes's experimental results, the average geometrically necessary boundaries were 44 only 10 nm, with nanocrystalline surface layer depth in excess of 4 μ m [7]. During 45 friction process, only one tenth of the energy was undertaken by wear, while most of 46 the energy was consumed in deformation, heat and noise et. al [8]. Thus it is supposed

47 that in case a suitable process is selected, wear loss can be controlled and more energy 48 can be consumed in plastic deformation. A thick nanocrystalline surface layer in 49 excess of 100 m underneath the worn surface of pure copper induced by sliding 50 against a WC-Co ball by utilizing a generic friction and wear tester has been reported 51 elsewhere by the current authors [9]. These results further experimentally verified 52 sliding friction as a potential approach to create nanocrystalline structures on the 53 surface layer of metallic materials.

54 As such, we have developed a surface nanocrystallization technology by means 55 of sliding friction treatment (SFT) with a specified device with enlarged sliding 56 amplitude and improved controllable contact condition to scale up sample size. This 57 work described the generation of nanostructured surface layer on pure copper and 58 tantalum by sliding friction process and reported subsequent changes in the 59 mechanical properties of the treated surfaces.

60

61 **2. Experimental procedures**

62 99.95 wt% pure copper and tantalum plates with a size of $200 \times 200 \times 3$ mm³ and a 63 roughness of 0.4 μ m were annealed at 973 K and 1273 K, respectively, for 60 minutes, 64 in order to eliminate the effect of mechanical processing on the surface and to 65 homogenize the microstructure. The experiments were conducted on a special 66 designed device in a ball-on-disc contact configuration as shown in Fig. 1(a), in which 67 a spherical WC-Co ball of 10 mm in diameter bearing a normal load was static and 68 the specimen (copper or tantalum) subjected to SFT was firmly installed in a table and

79 The microstructure of the surface layer of the treated samples was characterized 80 by using an Olympus PMG 3 optical microscopy (OM) and a JEOL JEM-2100 81 transmission electron microscope (TEM) operated at a voltage of 200 kV. Thin foil 82 samples for TEM observations were cut from the treated surface layer and thinned by 83 ion thinning at low temperatures.

84 X-ray photoelectron spectroscopy (XPS) was carried out on a Thermo Fisher 85 ESCACAB 250XI spectrometer, by using monochromatic Al Ka radiation and 86 detection pass energy ranging between 30 and 100 eV. Argon sputtering was applied 87 at a pressure of 1×10^{-7} Pa under a 3 kV beam accelerating voltage.

88 The as-treated plates were mechanically polished on the top surface to remove 1-2 89 m in depth to eliminate the roughness effect on tensile properties. Down-sized 90 tensile specimens shown in Fig. 1(c) were cut with the testing direction along the

91 sliding direction by using electro-discharging machining. Afterwards, mechanical 92 polishing was performed from back side of the treated sample to a mirror finish with a 93 designed thickness. Tensile tests were performed on a Tytron 250 Microforce Testing 94 System (MTS System Corporation, with a precision of force measurement of 10 mN) 95 at a strain rate 5×10^{-3} s⁻¹ at room temperature. A contactless MTS LX300 Laser 96 extensometer was used to calibrate and measure the strain of the tested sample during Cite 97 loading.

98

99 **3. Results and discussion**

100 Figure 2 shows the microstructure from longitudinal cross-section of the Cu 101 sample before and after SFT. Plastic deformation and traces of plastic flow are 102 evident in the treated surface layer, instead of the original CG structure. After SFT at 103 100 N, the topmost deformed subsurface layer features discontinuous in a wave 104 pattern. This is similar to the vortex structure appeared in some local zones of the 105 upmost worn subsurface, which has been usually found [10-12] and checked in details 106 by Yao [13] to be composed of severely refined grains. It is apparent that the plastic 107 flow lines extended to a greater depth as the load increases to 200 N, and the 108 deformed subsurface layer tends to be continuous, with grain boundaries bent towards 109 one direction with decreasing depth toward the surface.

110 As revealed by TEM morphologies and the corresponding selected area electron 111 diffraction (SAED) pattern in Figs. 2(d) and (e), elongated grains with random 112 crystallographic orientations are formed in the top surface layer of the sample. The

113 average transverse axis grain size (d_t) and longitudinal axis grain size (d_l) are 60 and 114 110 nm, respectively, although a certain number of grains approaching 200 nm are 115 also present. The grain size is slightly larger than that in the surface layer of the Cu 116 sample subjected to SMGT (22 nm, 45 nm in transverse axis and longitudinal axis 117 size respectively) under liquid nitrogen [4] and SMAT (10 nm) for 30 min [14].

118 Microstructures of the longitudinal cross-sectional Ta sample before and after 119 SFT are presented in Figs. 3(a)-(c). Initial Ta sample has an equiaxed grain structure 120 with size of 30-60 μ m (Fig. 3(a)), and after SFT at a load of 200 N, a plastic deformed 121 surface layer with the thickness exceeding $100 \mu m$ is formed clearly as shown in Fig. 122 3(b). When sliding load increases to 500 N, the deformation layer of about 300 μ m in 123 depth is reached, as revealed in Fig. 3(c). Plastic flow lines are inclined to the surface 124 as they approached the worn surface, similar to the case for Cu in Fig. 2(c). The 125 detailed TEM observations show that roughly equiaxed grains with size ranging from 126 3 to 15 nm and an average grain size of 7 nm are formed in the topmost layer (Figs. 127 $3(d)$ and (e)).

128 Materials in sliding contact develop large plastic strain and strain rate adjacent to 129 the sliding interface in that actual contact took place in some asperities of the friction 130 pair. Plastic shear strains in the range of 10–1000 have been reported [7, 15-17]. For 131 example, based on the volume grain boundary area and von Mises relation, Hughes 132 [17] extrapolated that the strain in the top-surface of copper subjected to friction was 133 roughly 25 and the maximum shear strain rates being up to 5×10^3 s⁻¹. Owing to much 134 high strain and high strain rate, a nanocrystalline structure will be produced, which

135 had been validated by large-scale molecular dynamics simulations [18] and 136 considerable amounts of experiments over the past several decades [5-7, 19]. Current 137 SFT has induced nanocrystalline structure on the subsurface for both Cu and Ta, and 138 finer grain size for Ta than that for Cu may be attributed to the difficulty in 139 dislocations recovery due to its higher melting temperature.

140 XPS results (Fig. 4) showed that C and O coming from the mating ball or 141 atmosphere were detected on the treated surface of the Cu and Ta samples, while the 142 impurity contents decreased remarkably away from the surface. For example, after 143 etching 840 s, the C content was decreased by two orders of magnitude for the two 144 samples. The measured values from XPS are summarized in Table 1. It is reasonable 145 to obtain clean nanocrystalline surface layer for Ta because the lubricant oil used 146 could alleviate wear and isolate the air from the contact surfaces. For the metals 147 sliding in air, it is common to produce oxides which are then available to 148 mechanically mix with unoxidized metal to form a mechanically mixed surface layer 149 [16, 20, 21]. In this work, large moving distance up to 50 mm imposed played a 150 dominant role in reducing impurity of the surface layer. Compared with our previous 151 study with a much lower travel distance (0.5 mm), the severe oxidation process and 152 subsequent behavior of oxide debris in between contact surfaces subjected to relative 153 slip will result in the thick oxide layer [22]. While in the present study during the 154 large distance sliding, the heat generated during friction should be radiated easily, 155 which can significantly alleviate oxidation. Moreover, it benefitted for the oxide 156 debris and contamination from transferred materials to be removed from the contact

157 zone. Consequently, a much thinner contamination layer was generated on the 158 nanostructured surface layer of the treated sample.

159 Results from uniaxial tensile tests in Fig. 5 showed that the nanocrystalline 160 samples exhibited much higher yield strength (YS) and ultimate tensile strength (UTS) 161 compared with their CG counterparts for both Ta and Cu. The YS of the SFT Cu and 162 SFT Ta have reached 450 MPa and 720 MPa, respectively, which are considerably 163 higher than that of the corresponding CG samples (75 MPa for Cu and 300 MPa for 164 Ta). However, the plasticity was depressed for the nanocrystalline samples, with an 165 elongation-to-failure less than 2% for both materials. It was reasonable that 166 nanocrystalline grains tended to significantly lose work hardening on deformation 167 owing to their very low dislocation storage efficiency inside tiny grains [23]. It was 168 noted that the SFT Cu with a 200 μ m in thickness exhibited a YS of 300 MPa and a 169 moderate elongation of 4.4. It was in well agreement with the results in [24] and 170 further verified that an approach using gradient nano-grained layers as advanced 171 coatings of bulk materials could enhance strength-ductility synergy of materials.

172

173 **4. Conclusions**

174 The sliding friction was used to refine the grain structure on the surface of pure 175 Cu and Ta plates with a size scale up to 100 mm \times 150 mm. The average grain size in 176 the upmost surface layer of the Cu and Ta can be reduced down to 60 nm and 7 nm 177 respectively. Surface contaminated layer from the ball-disc sliding is reasonably low 178 in depth. The yield strength of the Cu and Ta has been improved from 75 MPa and

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- 217

218 **Table 1.** Variations of the element contents (in wt. %) with sputtering time from the

219 treated surface in the SFT samples.

220						
	SFT Cu					
221		0 _s	60 s	240 s	840 s	
	Cu	31	91.2	98.8	99.5	
222	Ω	22	1.89	0.35	0.11	
	\mathcal{C}	47	6.91	0.85	0.39	
223	SFT Ta					
		0 _s	60 s	240 s	840 s	
224	Ta	35.55	82.5	95.68	98.61	
	Ω	29.35	16.16	3.46	1.34	
225	\mathcal{C}	35.1	1.34	0.86	0.25	

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Figure 1. (a) Schematic illustrations of the sliding friction treatment set-up, (b) a photograph of a Cu sheet after sliding friction treatment and (c) the geometry of the tensile specimen.

Figure 2. Cross-sectional optical images of (a) the original and SFT Cu samples under load of (b) 100 N and (c) 200 N, (d) a bright-field TEM image and a corresponding SAED insert showing the microstructure at the topmost surface in (c). Doubly pointed arrow indicates the sliding direction.

Figure 3. Cross-sectional optical images of (a) the original and SFT Ta samples under load of (b) 200 N and (c) 500 N. (d) A bright-field TEM image and (e) a dark-field TEM image showing the microstructure at the topmost surface layer in (c). Doubly pointed arrow indicates the sliding direction.

Figure 4. X-ray photoelectron spectra at different etching depths from the surface in the SFT

Cu and Ta samples.

Figure 5. (a) Tensile true stress-strain curves and dimensions of the tensile sample (inset), and (b) summaries of the data of the surface layer in SFT samples with different thickness as indicated, in comparison with the corresponding CG samples.